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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/653,105	09/03/2003	Bin Yu	H1492	2960	
45114 7	590 08/12/2004		EXAMINER		
HARRITY & SNYDER, LLP		VU, HUNG K			
11240 WAPLES MILL ROAD					
SUITE 300			ART UNIT	PAPER NUMBER	
FAIRFAX, V	A 22030	,	2811		

DATE MAILED: 08/12/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	ØK
	10/653,105	YU ET AL.	
Office Action Summary	Examiner	Art Unit	T
	Hung K. Vu	2811	
The MAILING DATE of this communic Period for Reply	ation appears on the cover sheet w	ith the correspondence a	ddress
A SHORTENED STATUTORY PERIOD FO THE MAILING DATE OF THIS COMMUNIC - Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this communic - If the period for reply specified above is less than thirty (30) - If NO period for reply is specified above, the maximum statu - Failure to reply within the set or extended period for reply with Any reply received by the Office later than three months after earned patent term adjustment. See 37 CFR 1.704(b).	ATION. 37 CFR 1.136(a). In no event, however, may a nication. days, a reply within the statutory minimum of thir tory period will apply and will expire SIX (6) MON II, by statute, cause the application to become AE	reply be timely filed ty (30) days will be considered time ITHS from the mailing date of this BANDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed	on		
2a) This action is FINAL . 2b	n)⊠ This action is non-final.		
3) Since this application is in condition for closed in accordance with the practice	•	• •	e merits is
Disposition of Claims			
 4) Claim(s) 1-20 is/are pending in the ap 4a) Of the above claim(s) 10-15 is/are 5) Claim(s) is/are allowed. 6) Claim(s) 1-9 and 16-20 is/are rejected 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction 	withdrawn from consideration.	·	
Application Papers			
9) The specification is objected to by the			
10) The drawing(s) filed on is/are: a	• • • • • • •	•	
Applicant may not request that any objecti			NED 4 4044 B
Replacement drawing sheet(s) including the sale of the	•	• •	• •
Priority under 35 U.S.C. § 119			
<u> </u>	ocuments have been received. ocuments have been received in A the priority documents have been al Bureau (PCT Rule 17.2(a)).	pplication No received in this Nationa	l Stage
Attachment(s)			
1) Notice of References Cited (PTO-892)		Summary (PTO-413)	
 Notice of Draftsperson's Patent Drawing Review (PTo3) Information Disclosure Statement(s) (PTO-1449 or Paper No(s)/Mail Date 9/3/3,5/19/4,5/21/. 		s)/Mail Date nformal Patent Application (PT 	⁻ O-152)

DETAILED ACTION

Election/Restrictions

1. Applicant's election of Invention of Group I, Claims 1-9 and 16-20 in the reply filed on 06/18/04 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).

Applicant's election without traverse of Invention of Group I, Claims 1-9 and 16-20 in the reply filed on 08/16/04 is acknowledged.

Claims 10-15 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected Invention, there being no allowable generic or linking claim.

Election was made without traverse in the reply filed on 08/16/04.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-2, 5-9 and 16-20 are rejected under 35 U.S.C. 102(e) as being anticipated by Fried et al. (PN 6,657,252).

Fried et al. discloses, as shown in Figures 1-13, a semiconductor device, comprising:

a substrate (90);

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an insulating layer (99) formed on the substrate;

a fin (100) formed on the insulating layer and including a plurality of side surfaces and a top surface;

a first gate (115) formed on the insulating layer proximate to one of the plurality of side surfaces of the fin;

a second gate (115) formed on the insulating layer separate from the first gate and proximate to another one of a plurality of side surfaces of the fin;

a protective layer (116) formed above the fin, the first gate, and the second gate; a third gate (120) formed over the protective layer and over the fin.

With regard to claim 2, Fried et al. discloses the device further including:

first and second dielectric layers formed along the plurality of side surfaces of the fin and in contact with the first and second gates, respectively.

With regard to claim 5, Fried et al. discloses the fin comprises at least one of silicon and germanium.

With regard to claim 6, Fried et al. discloses the insulating layer comprises a buried oxide layer.

With regard to claim 7, Fried et al. discloses the device further comprising:

a source and a drain region formed above the insulating layer and adjacent a respective first and second end of the fin.

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With regard to claim 8, Fried et al. discloses the first, second, and third gates are independently addressable.

With regard to claim 9, Fried et al. discloses the first and second gates are electrically connected to one another and the third gate is independently addressable from the first and second gates.

With regard to claim 16, Fried et al. discloses, as shown in Figures 1-13, a MOSFET device comprising:

a substrate (90);

fin;

an insulating layer (99) formed on the substrate;

a conductive fin (100) formed on the insulating layer;

gate dielectric layers (110) formed on side surface of the conductive fin;

a first gate material layer (115) formed on the insulating layer and around the conductive

a protective layer (116) formed over the conductive fin and the first gate material;

a second gate material layer(120) formed over the protective layer and over the conductive fin.

With regard to claim 17, Fried et al. discloses the MOSFET device is a FinFET.

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With regard to claim 18, Fried et al. discloses the first and second gate material layers are formed

of polysilicon.

With regard to claim 19, Fried et al. discloses the gate dielectric layers and the conductive fin

break the first gate material layer into independently addressable first and second gate of the

MOSFET device.

With regard to claim 20, Fried et al. discloses the second gate material forms a third

independently addressable gate of the MOSFET device.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all 3.

obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the

manner in which the invention was made.

Claims 3 and 4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Fried et al.

(PN 6,657,252).

Although Fried et al. does not teach the thickness of the protective layer and the third gate, as

that claimed by Applicants, however, it would have been obvious to one having ordinary skill in

the art at the time the invention was made to form the protective layer and the third gate having a

desired thickness, since it has been held that discovering an optimum value of a result effective

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variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215

(CCPA 1980).

Conclusion

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4. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Hung K. Vu whose telephone number is (571) 272-1666. The

examiner can normally be reached on Mon-Thurs 6:00-3:30, alternate Friday 7:00-3:30, Eastern

Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Eddie C. Lee can be reached on (571) 272-1732. The Central Fax Number for the

organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308-0956.

Vu

August 7, 2004

Hung Vu

Patent Examiner